DATA SHEET





ADVANCED MATERIALS

Nickel Chromium (NiCr) Sputtering Targets for Large Area Coating Applications

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Nickel-Chromium (NiCr) Sputtering Targets for Large Area Coating Applications

Materion Advanced Materials, now expanded with the addition of the Heraeus target materials business, is the world's leading supplier of sputtering targets for large area coatings. To achieve optimal results during the deposition process requires targets capable of consistently producing uniform thin films and quality materials that meet or exceed industry standards. Our high purity NiCr sputtering targets are specifically developed to produce low defect and high performance thin films.

APPLICATIONS

NiCr layers are often used in low-e or solar control layer stacks. Their purpose is to mostly act as the oxidation barrier for the silver layer, but they can also be used as the absorbing layer in specific sun protection coatings.

Since NiCr layers are generally sputtered as extremely thin layers (2-5 nm), perfect thickness homogeneity is necessary. Thus, the target materials must also be of extremely high homogeneity.

GEOMETRIES

NiCr targets are mostly used as single piece monolithic planar targets with lengths of up to 3.8 m. We produce NiCr targets for use in all commercially available sputter tools and can provide customdesigned special geometries as well.

NiCr targets are usually clamped onto the cathode. Solder bonded targets are available upon request.

COMPOSITION

The most popular composition for the application in low-e blocker layers is NiCr 80/20 wt%. Other compositions, including additional alloying components, are available upon request.

PURITY

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NiCr targets for large area coating are usually of 2N8 (99.8%) purity.

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PRODUCTION

Planar NiCr targets are usually produced by Vacuum Induction Melting (VIM) and casting, followed by a well-defined thermomechanical treatment to adjust a perfectly homogeneous microstructure. Single piece "jumbo" targets can be produced up to Cr contents of 40 wt%. Multi-piece target constructions (segment length ~ I m) of up to 50 wt% Cr are also possible.

At higher Cr content, or when more complex compositions are required, powder metallurgical production techniques may be necessary.

Materion uses DIN EN ISO9001:2008 certified procedures to guarantee the highest and most consistent product reliability. We strive for continuous process improvements using statistical process control. In addition to detailed specifications and sophisticated analytical methods, our employees are dedicated to the highest quality standards.

RECYCLING

NiCr targets, particularly when clamped, can be recycled after consumption. Different recycling programs are available depending on individual logistical conditions. Discuss best choice with your Materion representative.

PHYSICAL DATA FOR NICR 80/20 WT%	
Density	8.5 g/cm3
Coefficient of Thermal Expansion	3.3·10-6 K-1
Elastic Modulus	197 KN/mm ²
Electrical Resistivity	II2 μΩcm
Thermal Conductivity	5. W/(m·K)
Melting Range	ca. 1400-1420 °C

MATERIAL CHARACTERISTICS FOR STANDARD PLANAR 2N8 NICR 80/20 TARGETS

Nickel (Ni)	80+/-1 wt %
Chromium (Cr)	20+/- wt %
Copper (Cu)	< 400 ppm
Cobalt (Co)	< 400 ppm
Iron (Fe)	< 750 ppm
Molybdenum (Mo)	< 200 ppm
Manganese (Mg)	< 200 ppm
Titanium (Ti)	< 200 ppm
Sum of all detected impurities	<2000 ppm

BENEFITS

- Target material of extremely high homogeneity
- Custom designed special geometries available
- Compositions and purity beyond the popular NiCr are available, including additional alloying components
- Single piece "jumbo" targets of up to 40 wt% Cr
- Multi-piece target constructions of up to 50 wt%
- NiCr targets can be recycled after consumption
- Company dedicated to Quality Assurance and ISO
 9001:2008 certified procedures





ADVANCED MATERIALS

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MATERION CORPORATION www.materion.com

MATERION ADVANCED MATERIALS is a global supplier of premier specialty materials for large area coatings particularly glass for architectural, automotive and residential applications. Our products include high purity precious and non-precious thin film deposition materials that deliver uniform coatings, increase yield and reduce costs. Our engineered solutions include new material development as well as standard planar, cast rotatable, and plasma sprayed rotatable sputtering targets with unique geometrics available in precious metal or customized alloys.